Front Matter: Volume 7062


Event: Optical Engineering + Applications, 2008, San Diego, California, United States
Laser Beam Shaping IX

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Editors

11–12 August 2008
San Diego, California, USA

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Please use the following format to cite material from this book:


ISSN 0277-786X
ISBN 9780819472823

Published by
SPIE
P.O. Box 10, Bellingham, Washington 98227-0010 USA
Telephone +1 360 676 3290 (Pacific Time) · Fax +1 360 647 1445
SPIE.org

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# Contents

## SESSION 1  
FEMTOSECOND LASER BEAM SHAPING

<table>
<thead>
<tr>
<th>Session</th>
<th>Title</th>
<th>Authors</th>
</tr>
</thead>
<tbody>
<tr>
<td>7062 02</td>
<td>Smart spatio-temporal beam shaping with thin-film micro-optics (Keynote Paper)</td>
<td>R. Grunwald, M. Bock, Max Born Institute for Nonlinear Optics and Short-Pulse Spectroscopy (Germany); S. Hulerath-von Luepke, Bremen Institute for Applied Beam Technology (Germany)</td>
</tr>
<tr>
<td>7062 04</td>
<td>Micro-optic array applications in terawatt ultrafast laser amplifiers</td>
<td>A. D. DiChiara, J. Waesche, S. Palaniyappan, N. Ekanayake, B. C. Walker, Univ. of Delaware (United States)</td>
</tr>
<tr>
<td>7062 05</td>
<td>Compression of ultrashort pulses by using refractive elements</td>
<td>C. Y. Ramírez-Corral, M. Rosete-Aguilar, J. Garduño-Mejía, R. Ortega-Martínez, Univ. Nacional Autónoma de México (Mexico)</td>
</tr>
</tbody>
</table>

## SESSION 2  
VORTEX AND NON-DIFFRACTING BEAMS I

<table>
<thead>
<tr>
<th>Session</th>
<th>Title</th>
<th>Authors</th>
</tr>
</thead>
<tbody>
<tr>
<td>7062 07</td>
<td>Characterization of elliptic dark hollow beams (Invited Paper)</td>
<td>J. C. Gutiérrez-Vega, Tecnológico de Monterrey (Mexico)</td>
</tr>
<tr>
<td>7062 09</td>
<td>Complex scalar fields using amplitude-only spatial light modulators</td>
<td>C. López-Mariscal, National Institute of Standards and Technology (United States); J. C. Gutiérrez-Vega, Tecnológico de Monterrey (Mexico)</td>
</tr>
</tbody>
</table>

## SESSION 3  
VORTEX AND NON-DIFFRACTING BEAMS II

<table>
<thead>
<tr>
<th>Session</th>
<th>Title</th>
<th>Authors</th>
</tr>
</thead>
<tbody>
<tr>
<td>7062 0B</td>
<td>Accurate phase mapping of nondiffracting singular beams</td>
<td>C. López-Mariscal, National Institute of Standards and Technology (United States); D. Burnham, D. Rudd, The Univ. of St. Andrews (United Kingdom); D. McGloin, Univ. of Dundee (United Kingdom); J. C. Gutiérrez-Vega, Tecnológico de Monterrey (United States)</td>
</tr>
<tr>
<td>7062 0D</td>
<td>Beam shaping with vectorial vortex beams under low numerical aperture illumination condition</td>
<td>J. Dai, Q. Zhan, Univ. of Dayton (United States)</td>
</tr>
</tbody>
</table>

## SESSION 4  
MEASUREMENT AND THEORY

<table>
<thead>
<tr>
<th>Session</th>
<th>Title</th>
<th>Authors</th>
</tr>
</thead>
<tbody>
<tr>
<td>7062 0F</td>
<td>Laser beam shaper alignment and analysis techniques</td>
<td>T. E. Lizotte, O. Ohar, T. Tuttle, Hitachi Via Mechanics USA Inc. (United States)</td>
</tr>
</tbody>
</table>
Beam profiling at focus: essential for beam shaping [7062-16]
L. I. Green, Ophir-Spiricon, Inc. (United States)

Comparison between a super Gaussian and a “true” top hat [7062-18]
A. Stockholm, J. G. Smith, MEMS Optical Inc. (United States)

SESSION 5 DESIGN AND FABRICATION I

Diamond micro-milling for array mastering (Invited Paper) [7062-19]
N. C. R. Holme, T. W. Berg, P. G. Dinesen, Kaleido Technology ApS (Denmark)

UV beam shaper alignment sensitivity: grayscale versus binary designs [7062-20]
T. E. Lizotte, Hitachi Via Mechanics USA Inc. (United States)

Diffractive, aspheric, or spherical beam transformers: a comparison in manufacturability [7062-21]
J. G. Smith, A. Stockholm, MEMS Optical, Inc. (United States)

SESSION 6 DESIGN AND FABRICATION II

Refractive statistical concave 1D diffusers for laser beam shaping [7062-25]
R. Bitterli, M. Kim, T. Scharf, H.-P. Herzig, Univ. of Neuchâtel (Switzerland); A. Bich, C. Dumouchel, S. Roth, R. Völkel, K. J. Weible, SUSS MicroOptics SA (Switzerland)

Stochastic tandem microlens arrays for beam homogenization [7062-26]
F. C. Wippermann, D. Radtke, P. Dannberg, U. D. Zeitner, A. Bräuer, Fraunhofer Institute for Applied Optics and Precision Engineering (Germany)

Randomly varying micro-optical elements for the generation of uniform intensity profiles in coherent laser sources [7062-27]
K. J. Weible, A. Bich, S. Roth, C. Dumouchel, P. Pernet, M. Eisner, R. Völkel, SUSS MicroOptics SA (Switzerland); R. Bitterli, T. Scharf, W. Noell, Univ. of Neuchâtel (Switzerland)

Simultaneous multiple uniform spot generation with micro optics [7062-28]
J. Fruendt, M. Jarczynski, T. Mitra, LIMO Lissotschenko Mikrooptik GmbH (Germany)

Free form micro-optics enables uniform off-axis illumination and superposition of high power laser devices [7062-29]
T. Bizjak, O. Homburg, A. Bayer, T. Mitra, L. Aschke, LIMO Lissotschenko Mikrooptik GmbH (Germany)

SESSION 7 APPLICATIONS

Laser beam interference and its applications in optical micromanipulation (Invited Paper) [7062-30]
T. Čižmář, Institute of Scientific Instruments (Czech Republic) and Univ. of St. Andrews (United Kingdom); P. Zemánek, M. Šiler, Institute of Scientific Instruments (Czech Republic); V. Garcés-Chávez, K. Dholakia, Univ. of St. Andrews (United Kingdom); V. Kollárová, Z. Bouchal, Palacky Univ. (Czech Republic)
Continuous phase plate polishing using magnetorheological finishing [7062-31]
M. Tricard, P. Dumas, QED Technologies (United States); J. Menapace, Lawrence Livermore National Labs. (United States)

Polarisation distribution for internal conical diffraction and the superposition of zero and first order Bessel beams [7062-52]
D. O'Dwyer, C. Phelan, Y. Rakovich, Trinity College Dublin (Ireland); T. Cizmar, K. Dholakia, Univ. of St. Andrews (United Kingdom); J. F. Donegan, J. G. Lunney, Trinity College Dublin (Ireland)

Beam shaping of line generators based on high power diode lasers to achieve high intensity and uniformity levels [7062-33]
A. Bayer, J. Meinschien, T. Mitra, M. Brodner, LIMO Lissotschenko Mikrooptik GmbH (Germany)

Erbium-doped tunable fiber laser [7062-34]
A. Castillo-Guzmán, Univ. Autonoma de Nuevo Leon (Mexico); G. Anzueto-Sánchez, Univ. Politecnica de Chiapas (Mexico); R. Selvas-Aguilar, Univ. Autonoma de Nuevo Leon (Mexico); J. Estudillo-Ayala, R. Rojas-Laguna, Univ. de Guanajuato (Mexico); N. S. Kazak, V. Belyi, B.I. Stepanov Institute of Physics (Belarus); A. Martínez-Ríos, Ctr. de Investigaciones en Óptica, A.C. (Mexico)

Intracavity mode competition between classes of flat-top beams [7062-36]
I. Litvin, CSIR National Laser Ctr. (South Africa) and Univ. of Stellenbosch (South Africa); P. W. Loveday, C. S. Long, CSIR Material Science and Manufacturing (South Africa); M. G. McLaren, CSIR National Laser Ctr. (South Africa) and Univ. of the Witwatersrand (South Africa); A. Forbes, CSIR National Laser Ctr. (South Africa) and Univ. of KwaZulu-Natal (South Africa)

Push-pull electrostatic deformable mirrors [7062-37]
S. Bonora, F. Frassetto, G. Naletto, L. Poletto, CNR- INFM, National Institute for the Physics of Matter (Italy)

POSTER SESSION

Beam shaping system based on polymer spherical gradient refractive index lenses [7062-41]
R. N. Zahreddine, R. S. Lepkowicz, R. M. Bunch, Rose-Hulman Institute of Technology (United States); E. Baer, A. Hiltner, Case Western Reserve Univ. (United States)

Fresnel ellipsoid approach for Gaussian beam focusing [7062-42]
G. Thériault, R. Tremblay, N. McCarthy, COPL, Univ. Laval (Canada)

Focal shift effect in vector parabolic-Gauss beams [7062-45]
R. I. Hernandez-Aranda, J. C. Gutiérrez-Vega, Tecnológico de Monterrey (Mexico)

Propagation of obstructed Bessel and Bessel-Gauss beams [7062-46]
I. A. Litvin, CSIR National Laser Ctr. (South Africa) and Univ. of Stellenbosch (South Africa); M. G. McLaren, CSIR National Laser Ctr. (South Africa) and Univ. of the Witwatersrand (South Africa); A. Forbes, CSIR National Laser Ctr. (South Africa) and Univ. of KwaZulu-Natal (South Africa)
Variable flattened Gaussian beam order selection by dynamic control of an intracavity diffractive mirror [7062-47]
A. Forbes, CSIR National Laser Ctr. (South Africa) and Univ. of KwaZulu-Natal (South Africa); C. S. Long, CSIR Material Science and Manufacturing (South Africa); I. Litvin, CSIR National Laser Ctr. (South Africa) and Univ. of Stellenbosch (South Africa); P. W. Loveday, CSIR Material Science and Manufacturing (South Africa); V. Belyi, N. S. Kazak, B.I. Stepanov Institute of Physics (Belarus)

Laser beam propagation characteristics of incoherently added diode bars [7062-48]
A. Forbes, CSIR National Laser Ctr. (South Africa) and Univ. of KwaZulu-Natal (South Africa); S. Ngcobo, D. Esser, D. Preussler, C. Bollig, CSIR National Laser Ctr. (South Africa)

Radiometry of flashing LED sources [7062-49]
D. A. Gregory, S. Medley, A. Roberts, The Univ. of Alabama in Huntsville (United States)

Author Index
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1 Femtosecond Laser Beam Shaping
Fred M. Dickey, Sandia National Laboratories (United States)
2 Vortex and Non-diffracting Beams I  
John A. Hoffnagle, IBM Almaden Research Center (United States)  

3 Vortex and Non-diffracting Beams II  
John A. Hoffnagle, IBM Almaden Research Center (United States)  

4 Measurement and Theory  
David L. Shealy, The University of Alabama at Birmingham (United States)  

5 Design and Fabrication I  
Kenneth J. Weible, SUSS MicroOptics SA (Switzerland)  

6 Design and Fabrication II  
Kenneth J. Weible, SUSS MicroOptics SA (Switzerland)  

7 Applications  
Todd E. Lizotte, Hitachi Via Mechanics USA, Inc. (United States)